

AMENDMENTS TO THE CLAIMS

Please enter the following amendments:

1. (Currently Amended) A method of manufacturing a plasma display panel, in which a plurality of structures of the plasma display panel are formed with photolithography, wherein at least a position on a photosensitive material corresponding to one of the structures of the plasma display panel is exposed twice using successive first and second exposures, each of the structures extends primarily in a lengthwise direction and has a width w in a widthwise direction orthogonal to the lengthwise direction, and a photomask and the plasma display panel photosensitive material are moved relative to each other within an allowable range of displacement in an exposure pattern, by a distance less than w between the first and second exposures.

2. (Currently Amended) A method of manufacturing a plasma display panel, in which a plurality of ~~structures~~ electrodes of the plasma display panel are formed with photolithography, wherein at least a position on a photosensitive material corresponding to one of the ~~structures~~ electrodes of the plasma display panel is exposed twice using successive first and second exposures, the electrodes are disposed periodically with a pitch p, and a photomask and the plasma display panel photosensitive material are moved relative to each other by multiple cycles of periodicity included in an exposure pattern, and also within an allowable range of displacement at the position, two or more integral times the distance p between the first and second exposures.

3 – 7. (Canceled)

8. (Currently Amended) The method according to claim [[4]] 1, wherein the structures are address electrodes formed by exposing a photosensitive silver paste polymerized by exposure to light.

9. (Currently Amended) The method according to claim [[5]] 2, wherein the structures electrodes are address electrodes formed by exposing a photosensitive silver paste polymerized by exposure to light.

10. (Currently Amended) The method according to claim [[6]] 12, wherein the structures electrodes are address electrodes formed by exposing a photosensitive silver paste polymerized by exposure to light.

11. (Canceled)

12. (New) A method of manufacturing a plasma display panel, in which a plurality of electrodes of the plasma display panel are formed with photolithography, wherein at least a position on a photosensitive material corresponding to one of the electrodes is exposed twice using successive first and second exposures, the electrodes each extend primarily in a lengthwise direction and are disposed periodically with a pitch p , and a photomask and the photosensitive material are moved relative to each other in the lengthwise direction by a distance less than p between the first and second exposures.